**The following is an English version of the official Japanese announcement, which has been given to the Tokyo Stock Exchange and the media in Tokyo, Japan.**

January 22, 2020

For Immediate Release

SPARX Group Co., Ltd.
President and Group CEO Shuhei Abe
(TSE1: 8739)

# Mirai Creation Fund II (two) Invests in QROMIS Inc., a Privately Held Fabless Technology Innovator in Silicon Valley

TOKYO—January 22, 2020—SPARX Group Co., Ltd. (SPARX; TSE1: 8739) today announced that its Mirai Creation Fund II (two) —established in July 2018—has executed an investment (the amount is not disclosed) in QROMIS, Inc. ("QROMIS"), a Silicon Valley fabless company with a disruptive innovation for enabling worldwide energy-efficient gallium nitride (GaN) electronics adoption. With this round of fundraising, QROMIS will drive continued expansion of its products portfolio, products applications and global customers base, as well as enhancing its unique technology and roadmaps.

Portfolio Company Outline

QROMIS is a privately held fabless technology innovator headquartered in Santa Clara, California and founded in 2015 by Cem Basceri and Vladimir Odnoblyudov. It is focused on energy-efficient and high-performance wide bandgap (WBG) semiconductor materials and device solutions which dramatically reduce global energy use and consumption. The Company, with its partners Micron Technology, Vanguard International Semiconductor (VIS) and Shin-Etsu Chemical Co., Ltd. (SEC) is poised to become one of the premier players in the rapidly growing, multi-billion dollar GaN materials, devices and electronics segments. With its groundbreaking and patented innovation, QROMIS enables 200mm diameter (scalable to 300mm) CMOS fab friendly substrate, epi and device wafer solutions for GaN-based power / RF electronics, LED devices, advanced displays, sensors, and other emerging high performance and energy efficient applications with an unmatched cost, performance and application scale. As a fabless company, QROMIS is driving the commercialization and the worldwide adoption of its unique solutions by leveraging VIS' and SEC's manufacturing platforms and their labeled products, and enabling the industry players to have access to such high performance and scalable GaN materials and device products from multiple sources.

Mirai Creation Fund I and Mirai Creation Fund II Summaries

The Mirai Creation Fund I began operations in November 2015 with financing of JPY 13.5 billion from three companies: Toyota Motor Corporation, Sumitomo Mitsui Banking Corporation, and SPARX, the Fund's general partner. Ultimately, the Fund received contributions from 20 companies, including the above three. Casting intelligent technologies, robotics, and hydrogen-economy technologies as core technologies of the future, Fund I has invested in approximately 50 companies and projects—from the US, the UK, Israel, Singapore, and Japan—that possess innovative technologies in these fields. In H2 2018, SPARX began managing the Mirai Creation Fund II, which targets the three existing Mirai Creation fields along with the two additional areas of electrification and new materials. As of December 31, 2019, the combined AUM for Fund I and Fund II were JPY 109.3 billion.
Mirai Creation Fund investment track record: https://mirai.sparx.co.jp/en/investment/

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